

In the Specification:

Please replace the paragraph beginning on page 17, line 5 with the following amended paragraph:

As shown in Fig. 12, a stripe of a photoresist film 64 is then formed on the layered composite 56 and the material layers 63 continuous to one another. The stripe of the photoresist film 64 is designed to extend in the second direction *DR2* so as to define the contour of a combined stripe in which the spin valve film 41 and the domain control stripe layers 42 are arranged in a row. An ion milling process is thereafter effected on the layered composite ~~57~~56 and the material layers 63. The layered composite ~~57~~56 and the material layers 63 are thus removed in a region adjacent the stripe of the photoresist film 64. The combined stripe 65 of the spin valve film 41 and the domain control stripe layers 42 can be obtained right below the stripe of the photoresist film 64 so as to extend in the second direction *DR2*, as shown in Fig. 13.